

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Serial No.	:	10/526,383	Confirmation No. :	3829	
Filing Date	:	13 September 2005	Art Unit	:	1752
First Named Inventor:		Nobuji Sakai	Examiner	:	Cynthia Hamilton
Customer No.	:	54884	Docket No.	:	Toyo-3
Title:	:	Radiation-Sensitive Negative-Type Resist Composition for Pattern Formation and Pattern Formation Method			

AMENDMENT AND RESPONSE

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir or Madam:

This Amendment is in response to the Office Action dated 21 March 2007.

Amendments to the claims begin on page 2.

Remarks begin on page 5.

Please amend the above-identified application without prejudice or disclaimer of subject matter as follows: